Ref #	Hits	Search Query	DBs	Default Operator	Piurals	Time Stamp
L1	242611	phenol\$2 or polyvinylphenol\$2 or hydroxystyrene or polyhydroxystyrene	US-PGPUB; USPAT	OR	ON	2005/02/20 17:39
L2	2921	(phenol\$2 or polyvinylphenol\$2 or hydroxystyrene or polyhydroxystyrene) same anthracene	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 17:39
L3	8416	barc or antireflective	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 17:40
L4	48	2 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:02
L5	46186	photoresist same (si or silicon)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:04
L6	1246	photoresist same photoacid	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:03
L7	664	5 and 6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR ·	ON	2005/02/20 18:03
L8	11	4 and 7	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:24
L9	35070	(polymer or resin) near3 (silicon or trimethylsilicon or trimethylsilyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:35

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L10	50	3 and 9 and 7	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:26
L11	4	4 and 7 and 9	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:27
L12	3	(polymer or resin) near3 (trimethylsilylmethacrylate or trimethylsilylacrylate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR ,	ON	2005/02/20 18:38
L13	0	(photoresist) near3 (trimethylsilylmethacrylate or trimethylsilylacrylate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2005/02/20 18:38
L14	0	(photoresist) same (trimethylsilylmethacrylate or trimethylsilylacrylate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:39
L15	17	(polymer or resin) same (trimethylsilylmethacrylate or trimethylsilylacrylate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:57
L16	3073	(photoresist or resist adj composition) and (barc or antireflective)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2005/02/20 18:40
L17	0	15 and 16	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2005/02/20 18:40

L18	0	3 and 17	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:58
L19	526	two adj layer adj resist	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:58
L20	4	19 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/20 18:58